

Docket No.: 4425-168

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : **BOX OFFICIAL DRAFTSMAN**
LU, YEN-TING : *Confirmation No. 4176*
U.S. Patent Application No. 09/919,868 : Group Art Unit: 1756
Filed: August 2, 2001 : Allowed: February 11, 2004
For: : Examiner: Christopher G. Young
METHOD FOR REDUCING LINE EDGE ROUGHNESS OF PHOTORESIST

LETTER SUBMITTING FORMAL DRAWINGS


Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Submitted herewith are 6 sheets of Replacement Formal Drawings in connection with the above referenced application.

Respectfully submitted,

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